WEST Search History

DATE: Friday, July 11, 2003

| Set Name Query side by side | | Hit Count Set Name result set | |
|---|--|-------------------------------|-----|
| DB = USPT, JPAB, EPAB, DWPI; PLUR = YES; OP = ADJ | | | |
| L22 | L21 same clean\$ adj2 composition | 6 | L22 |
| L21 | L14 with (citric or citrate or malic or tartaric or lactic or glycolic or tartaric or tartronic) | 2178 | L21 |
| L20 | L14 with (citric or citrate or malic or tartaric or lactic or glycolic or tartaric or tartronic) | 2178 | L20 |
| L19 | L17 and (semiconductor or wafer or substrate) | 108 | L19 |
| L18 | L17 and semiconductor | 1 | L18 |
| L17 | L15 same composition | 532 | L17 |
| L16 | L15 same clean\$3 composition | 7 | L16 |
| L15 | 114 same (citric or citrate or hydroxy adj3 propanetricarboxylic or citralite) | 2744 | L15 |
| L14 | (sorbic acid or sorbate or preservastat or hexadienoic or sorbistat or panasorb) | 15019 | L14 |
| L13 | L12 and (semiconductor or wafer or substrate) | 44 | L13 |
| L12 | (citrate or citric) with (sorbic or sorbate) with composition | 229 | L12 |
| L11 | citr\$3 with (sorbic or sorbate) with composition | 224 | L11 |
| L10 | citr\$3 with sorb\$ with composition | 814 | L10 |
| L9 | citr\$3 with sorb\$ with composition | 10 | L9 |
| L8 | citr\$3 with sorb\$ with composition | 814 | L8 |
| L7 | composition with ((antimicrobial or antibacterial) (agent)) with cleaning agent | 8 | L7 |
| L6 | cleaning composition with antimicrobial agent with cleaning agent | 0 | L6 |
| L5 | cleaning composition with antimicrobial gent with cleaning agent | 0 | L5 |
| L4 | L2 and \$5microbial | 0 | L4 |
| L3 | L2 and \$3microbial | 0 | L3 |
| L2 | L1 and CMP | 10 | L2 |
| L1 | andreas-michael\$.in. | 20 | L1 |

END OF SEARCH HISTORY

WEST

Generate Collection Print

L13: Entry 22 of 44

File: USPT

Mar 27, 1990

DOCUMENT-IDENTIFIER: US 4912021 A

TITLE: Developer-finisher compositions for lithographic plates

Brief Summary Text (2):

The present invention relates to developer-finisher compositions for photographic elements comprising photosensitive coatings on <u>substrates</u>, or more particularly to developer-finisher compositions for removing and desensitizing the non-image areas of exposed, usually negative working lithographic printing plates.

Brief Summary Text (3):

Lithographic printing plates generally are composed of an aluminum containing substrate which may or may not have been treated with a variety processes recognized in the art process including anodization, graining and hydrophilization. The thusly prepared substrate may then be applied with a photosensitive coating comprising a photosensitizer, binding resins, colorants, acid stabilizers, surfactants and other art recognized components. Common photosensitizers include diazo compounds, including polymeric diazonium condensates salts and photopolymerizable compositions. Sensitizers, binders and printing plates employing aromatic diazonium compounds are described in U.S. Pat. Nos. 3,175,906; 3,046,118; 2,063,631; 2,667,415; 3,867,147 and 3,679,419 which are incorporated herein by reference.

Brief Summary Text (23):

The invention further provides a method for preparing a photographic element which comprises imagewise exposing a photographic element comprising a light sensitive negative working or positive working photographic composition disposed on a substrate with sufficient actinic radiation to form a latent image and then simultaneously removing the non-image areas of said exposed element and desensitizing the non-image areas with a developer/finisher composition comprising the foregoing admixture.

Drawing Description Text (2):

As the first step in the production of photographic elements such as lithographic printing plates, a sheet <u>substrate</u> such as aluminum compositions suitable for the manufacture of lithographic printing plates such as, Alcoa 3003 and Alcoa 1100, which may or may not have been pretreated by standard graining and/or etching and/or anodizing techniques as are well known in the art, and also may or may not have been treated with a composition, such as polyvinyl phosphonic acid, suitable for use as a hydrophilizing layer for lithographic plates is coated with a light sensitive polymeric diazonium salt or photopolymer containing composition. Such compositions may also contain binding resins, such as polyvinyl formal resins, colorants acid stabilizers, surfactants, exposure indicators or other art recognized ingredients.

Drawing Description Text (4):

The photosensitive coating mixture is usually prepared in a solvent composition which is compatible with all the other composition ingredients. The light sensitive composition is then coated on the substrate and the solvent dried off.

CLAIMS:

20. The <u>composition</u> of claim 1 wherein component (a) comprises monosodium phosphate, and component (b) comprises phenoxy propanol, and component (c) comprises polyvinyl pyrrolidone, and component (d) comprises <u>citric</u> acid, and component (e) comprises sodium octyl sulfate, and component (f) <u>comprises</u> lithium benzoate, and component

(g) comprises sodium citrate and component (h) comprises potassium sorbate.